

## IN THE U.S. PATENT AND TRADEMARK OFFICE

I N F O R M A T I O N S H E E T

Applicant: AOYAGI, Yoshinobu  
IWAI, Souhachi  
HIRAYAMA, Hideki

Application No.:

Filed: August 30, 2001

For: IMPURITY DOPING METHOD FOR SEMICONDUCTOR AS WELL AS SYSTEM  
THEREFOR AND SEMICONDUCTOR MATERIALS PREPARED THEREBY

Priority Claimed Under 35 U.S.C. 119 and/or 120:

COUNTRY	DATE	NUMBER
Japan	09/01/00	2000-264743

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The above information is submitted to advise the USPTO of all  
relevant facts in connection with the present application. A timely  
executed Declaration in accordance with 37 CFR 1.64 will follow.

Respectfully submitted,

BIRCH, STEWART, KOLASCH & BIRCH, LLP

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